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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Application of:

Yi-Ming Sheu

Serial No.: 10/619,114

Filed: 07/14/2003

For: NARROW WIDTH EFFECT  
IMPROVEMENT WITH PHOTORESIST PLUG  
PROCESS AND STI CORNER ION  
IMPLANTATION

)  
)  
) Group Art Unit: 2823

)  
) Examiner: Brewster, William

)  
) Confirmation No.: 6852

)  
) TKHR Docket: 252016-1300  
) Top-Team Dkt: 0503-9540US  
)

Certificate of Mailing

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail, postage prepaid, in an envelope addressed to: Mail Stop Amendment; Commissioner for Patents, P.O. Box 1450, Alexandria, Virginia 22313-1450, on August 2, 2005.

  
Signature – Hui Chin Barnhill

**RESPONSE TO NON-FINAL OFFICE ACTION**

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, Virginia 22313-1450

Sir:

The Office Action mailed May 17, 2005 has been carefully considered. In response thereto, please consider the following remarks.